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Γ	APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
	10/636,162	08/07/2003	Hyeon-Seag Kim	0180124	3602	
	25700	7590 09/22/2004		EXAM	INER	1
	FARJAMI & FARJAMI LLP 26522 LA ALAMEDA AVENUE, SUITE 360			FENTY, JESSE A		•
		EJO, CA 92691	11E 300	ART UNIT	PAPER NUMBER	1
	,	,		2815		
				DATE MAILED: 09/22/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)
	10/636,162	KIM ET AL.
Office Action Summary	Examiner	Art Unit
	Jesse A. Fenty	2815
The MAILING DATE of this communication Period for Reply	on appears on the cover sheet w	ith the correspondence address
A SHORTENED STATUTORY PERIOD FOR F THE MAILING DATE OF THIS COMMUNICAT - Extensions of time may be available under the provisions of 37 of after SIX (6) MONTHS from the mailing date of this communicat - If the period for reply specified above is less than thirty (30) days - If NO period for reply is specified above, the maximum statutory - Failure to reply within the set or extended period for reply will, by Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	CION. CFR 1.136(a). In no event, however, may a cion. s, a reply within the statutory minimum of thir period will apply and will expire SIX (6) MON y statute, cause the application to become Al	reply be timely filed rty (30) days will be considered timely. NTHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).
Status		•
 1) ⊠ Responsive to communication(s) filed on 2a) ☐ This action is FINAL. 2b) ⊠ 3) ☐ Since this application is in condition for a closed in accordance with the practice un 	This action is non-final. Illowance except for formal mat	·
Disposition of Claims		
4) ⊠ Claim(s) <u>1-20</u> is/are pending in the applic 4a) Of the above claim(s) is/are wi 5) ⊠ Claim(s) <u>16-20</u> is/are allowed. 6) ⊠ Claim(s) <u>1,3-5,7-9,11-13 and 15</u> is/are re 7) ⊠ Claim(s) <u>2,6,10 and 14</u> is/are objected to 8) ☐ Claim(s) are subject to restriction	ithdrawn from consideration. ejected.	
Application Papers		
9)☐ The specification is objected to by the Ex		
• • • • • • • • • • • • • • • • • • • •	☐ accepted or b)☐ objected to	
Applicant may not request that any objection	• • • • • • • • • • • • • • • • • • • •	
Replacement drawing sheet(s) including the a		
Priority under 35 U.S.C. § 119		
12) Acknowledgment is made of a claim for fo	oroign priority under 25 LLS C	\$ 110(a) (d) or (f)
a) All b) Some * c) None of: 1. Certified copies of the priority docu 2. Certified copies of the priority docu 3. Copies of the certified copies of the application from the International E	uments have been received. uments have been received in <i>i</i> e priority documents have beer Bureau (PCT Rule 17.2(a)).	Application No n received in this National Stage
* See the attached detailed Office action for	a list of the certified copies not	t received.
Attachment(s)	, .	O (DTO 442)
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-93) Information Disclosure Statement(s) (PTO-1449 or PTO/Paper No(s)/Mail Date 	48) Paper No	Summary (PTO-413) (s)/Mail Date Informal Patent Application (PTO-152)

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1, 3-5,8, 9 and 11-13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Alvis (U.S. Patent No. 6,293,698 B1) in view of Young (U.S. Patent No. 6,680,484 B1).

In re claims 1 and 9, Alvis discloses a semiconductor test structure comprising:

A first metal line situated in a metal layer of said test structure;

A second metal line situated adjacent and substantially parallel to said first metal line, said second metal line being separated from said first metal line by a first distance;

An interlayer dielectric layer situated between said first metal line and said second metal line.

The limitations, "for determining ... failure" and "wherein said electromigration failure is determined ... line" are recitations of the intended use of the claimed device. Terms that simply set forth the intended use, a property inherent in or a function, do not differentiate the claimed composition of these elements from those known to prior art. The instant claims are directed to a structure patent, not a method of use, which is a separate patentable subject area. If the prior art structure reads on the claims, the intended use of the device does not add features to the claimed subject matter.

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Alvis does not expressly disclose the distance between the metal layers being equal to a minimum design rule separation distance. Young (column 7, lines 30-60) discusses the importance of design rule minimum width between metal layers. It would have been obvious for one skilled in the art at the time of the invention to place the metal layers of Alvis at the minimum design rule width as disclosed by Young for the purpose, for example, of setting the proper width as to determine proper current density variations between metal layers (Young; column 7, lines 57-61).

In re claims 3 and 11, Alvis in view of Young discloses the devices of claims 1 and 9 respectively, wherein said first metal line has a first width and said second metal line has a second width, said first width and said second width being substantially equal to minimum design rule width.

In re claims 4 and 12, Alvis in view of Young discloses the devices of claims 1 and 9 respectively, wherein a current is caused to flow through the metal lines (column 2, lines 31-32) by a voltage applied at either end of the line. Varying the direction of the current flow in routine experimentation would have been obvious to one skilled in the art and does not deem the claim allowable over the disclosed prior art.

In re claims 5 and 13, Alvis in view of Young discloses the devices of claims 1 and 9 respectively, but do not expressly disclose the length of the metal lines. The novelty of the prior art is the structure of the test devices, not the length of the wire. If so, length would have been specifically mentioned. Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to determine an optimum distance of the test line,

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since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. *In re Boesch*, 617 F. 2c 272, 205 USPQ 215 (CCPA 1980).

In re claim 8, Alvis in view of Young discloses the device of claim 1, wherein the metal lines are aluminum or copper (Young, column 6, line 1).

3. Claims 7 and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Alvis in view of Young as applied to claims 1 and 9 above, and further in view of Uzoh (U.S. Patent No. 6,465,376).

In re claims 7 and 15, Alvis in view of Young discloses the devices of claims 1 and 9 respectively, comprising an interlayer dielectric layer (33) encapsulating the metal layers, but does not expressly disclose the material to be a low-k dielectric. Uzoh discloses a similar device for improving electromigration that discloses the use of low-k silicon dioxide (2) as an interlayer dielectric. It would have been obvious for one skilled in the art at the time of the invention to use a well-known dielectric as disclosed by Uzoh for the device of Alvis/Young for the purpose, for example, of insulating and isolating the metal lines.

Allowable Subject Matter

- 4. Claims 2, 6, 10 and 14 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- 5. Claims 16-20 are allowed.

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6. The following is a statement of reasons for the indication of allowable subject matter:

The objected to and allowed claims reciting at least a further metal band that surrounds the first and second metal lines and interlayer dielectric layers being situated between the metal lines and the metal band is neither anticipated nor obvious over the prior art of record.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jesse A. Fenty whose telephone number is 571-272-1729. The examiner can normally be reached on 5/4-9 1st Fri. Off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on 571-272-1664. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jesse A. Fenty Examiner

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